Search Notes



Application/Control No.	Applicant(s)/Patent under Reexamination	Applicant(s)/Patent under Reexamination		
10/618,068	NAKAMURA ET AL.			
Examiner	Art Unit			
Ling-Siu Choi	1713			

SEARCHED						
Cla	iss	Subclass	Date		Examiner	
43	30	270.1	2/1/2007		LSC	
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	INTERFERENCE SEARCHED					
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SEARCH NOT (INCLUDING SEARCH)
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West and STN	2/1/2007	LSC
thiol compound-alkali-soluble resin- infrared absorbing agent		
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